PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Docket No: Q79837

Ken MIYAGI, et al.

Continuation of Appln. No.: 09/793,958

Parent Group Art Unit: 1752

Parent Confirmation No.: 2382

Parent Examiner: John S. CHU

Filed: February 27, 2001

For:

PHENOL NOVOLAK RESIN, PRODUCTION PROCESS THEREOF, AND POSITIVE

PHOTORESIST COMPOSITION USING THE SAME

INFORMATION DISCLOSURE STATEMENT UNDER 37 CFR §§ 1.97 and 1.98

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

In accordance with the duty of disclosure under 37 CFR §1.56, Applicants hereby notify the U.S. Patent and Trademark Office of the documents listed on the attached Form PTO/SB/08 A & B (modified), which are references of record in parent application No. 09/793,958. Applicants are not submitting duplicate copies of these references but request that they be listed on the face of any patent granted on the above application. (See 37 CFR §1.98(d)).

The submission of the listed documents is not intended as an admission that any such document constitutes prior art against the claims of the present application. Applicants do not waive any right to take any action that would be appropriate to antedate or otherwise remove any listed document as a competent reference against the claims of the present application.

Respectfully submitted,

L. Raul Tamayo

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WASHINGTON OFFICE

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Date: February 9, 2004

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Substitute for Form 1449 A & B/PTO		•	Complete if Known		
Substitute for Form 1449 A & B/PTO				Continuation of Appln No	09/793,958
INFO	RMATION	DISCLOS	HRE	Parent Confirmation No	2382
INFORMATION DISCLOSURE STATEMENT BY APPLICANT				Parent Filing Date	February 27, 2001
			AINI	First Named Inventor	Ken MIYAGI
(use as many sheets as necessary)				Parent Art Unit	1752
				Parent Examiner Name	John S Y Chu
Sheet	1	of	1	Attorney Docket Number	Q79837

U.S. PATENT DOCUMENTS						
Examiner Cit Initials* No	Cito	Document Number		Publication Date		
	No.1	Number	Kind Code ² (if known)	MM-DD-YYYY	Name of Patentee or Applicant of Cited Docume	
		US 5,604,077	Α	02-18-1997	Kono, et al.	
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FOREIGN PATENT DOCUMENTS							
Examiner Cite	Cite	Foreign Patent Document			Publication Date	Name of Patentee or	
Initials*			Applicant of Cited Document	Translation ⁶			
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NON PATENT LITERATURE DOCUMENTS				
		Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city, and/or country where published.	Translation ⁶	

Examiner Signature	Date Considered	

^{*}EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

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